

# PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2002-289269  
(43)Date of publication of application : 04.10.2002

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(51)Int.Cl. H01M 14/00  
H01L 31/04

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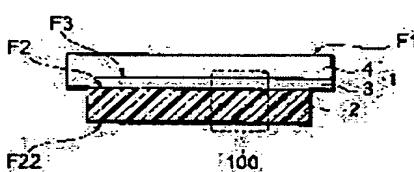
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## (54) MANUFACTURING METHOD OF PHOTOELECTRODE FOR DYE SENSITIZED SOLAR CELL AND MANUFACTURING METHOD OF DYE SENSITIZED SOLAR CELL

### (57)Abstract:

PROBLEM TO BE SOLVED: To provide a manufacturing method of a photoelectrode for a dye sensitized solar cell, showing an excellent photoelectric transducing efficiency, and a manufacturing method of a dye sensitized solar cell.

SOLUTION: The manufacturing method of the photoelectrode 10 for a dye sensitized solar cell, comprising a semiconductor electrode 2 with a light receiving surface F2 and a transparent electrode 1 arranged to adjoin the light receiving surface of the semiconductor electrode, is characterized in that it comprises a surface treatment process wherein electromagnetic waves within a wavelength range of 180-450 nm are emitted to the back surface F22 on the opposite side of the light receiving surface of the semiconductor electrode, and a pigment



adsorption process wherein sensitizing pigment P2 is adsorbed to the back surface obtained through the surface treatment process.

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**LEGAL STATUS**

[Date of request for examination] 05.12.2007

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]